

Panagiotis Argitis

List of Publications by Year in descending order

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208
papers

4,752
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87723

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docs citations

213
times ranked

6301
citing authors

#	ARTICLE	IF	CITATIONS
1	The Influence of Hydrogenation and Oxygen Vacancies on Molybdenum Oxides Work Function and Gap States for Application in Organic Optoelectronics. <i>Journal of the American Chemical Society</i> , 2012, 134, 16178-16187.	6.6	340
2	Hydrogenated under-stoichiometric tungsten oxide anode interlayers for efficient and stable organic photovoltaics. <i>Journal of Materials Chemistry A</i> , 2014, 2, 1738-1749.	5.2	161
3	A low temperature surface modification assisted method for bonding plastic substrates. <i>Journal of Micromechanics and Microengineering</i> , 2009, 19, 015007.	1.5	132
4	Molecular materials as interfacial layers and additives in perovskite solar cells. <i>Chemical Society Reviews</i> , 2020, 49, 4496-4526.	18.7	130
5	Harnessing photochemical internalization with dual degradable nanoparticles for combinatorial photochemotherapy. <i>Nature Communications</i> , 2014, 5, 3623.	5.8	120
6	Old Metal Oxide Clusters in New Applications: Spontaneous Reduction of Keggin and Dawson Polyoxometalate Layers by a Metallic Electrode for Improving Efficiency in Organic Optoelectronics. <i>Journal of the American Chemical Society</i> , 2015, 137, 6844-6856.	6.6	115
7	Polyoxometalate-Based Layered Structures for Charge Transport Control in Molecular Devices. <i>ACS Nano</i> , 2008, 2, 733-742.	7.3	113
8	Photodegradable Polymers for Biotechnological Applications. <i>Macromolecular Rapid Communications</i> , 2012, 33, 183-198.	2.0	111
9	Reduction of Tungsten Oxide: A Path Towards Dual Functionality Utilization for Efficient Anode and Cathode Interfacial Layers in Organic Light-Emitting Diodes. <i>Advanced Functional Materials</i> , 2011, 21, 1489-1497.	7.8	99
10	Fiber-Shaped Electronic Devices. <i>Advanced Energy Materials</i> , 2021, 11, 2101443.	10.2	74
11	Annealing-free highly crystalline solution-processed molecular metal oxides for efficient single-junction and tandem polymer solar cells. <i>Energy and Environmental Science</i> , 2015, 8, 2448-2463.	15.6	68
12	Solution processable tungsten polyoxometalate as highly effective cathode interlayer for improved efficiency and stability polymer solar cells. <i>Solar Energy Materials and Solar Cells</i> , 2013, 114, 205-213.	3.0	63
13	Surface passivation effect by fluorine plasma treatment on ZnO for efficiency and lifetime improvement of inverted polymer solar cells. <i>Journal of Materials Chemistry A</i> , 2016, 4, 11844-11858.	5.2	62
14	High Sensitivity Resists for EUV Lithography: A Review of Material Design Strategies and Performance Results. <i>Nanomaterials</i> , 2020, 10, 1593.	1.9	62
15	Porphyrin oriented self-assembled nanostructures for efficient exciton dissociation in high-performing organic photovoltaics. <i>Journal of Materials Chemistry A</i> , 2014, 2, 182-192.	5.2	60
16	An advanced epoxy novolac resist for fast high-resolution electron-beam lithography. <i>Journal of Vacuum Science & Technology an Official Journal of the American Vacuum Society B, Microelectronics Processing and Phenomena</i> , 1995, 13, 3030.	1.6	57
17	Suppressing the Photocatalytic Activity of Zinc Oxide Electron-Transport Layer in Nonfullerene Organic Solar Cells with a Pyrene-Bodipy Interlayer. <i>ACS Applied Materials & Interfaces</i> , 2020, 12, 21961-21973.	4.0	57
18	A biomolecule friendly photolithographic process for fabrication of protein microarrays on polymeric films coated on silicon chips. <i>Biosensors and Bioelectronics</i> , 2007, 22, 1994-2002.	5.3	56

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19	High performance organic light emitting diodes using substoichiometric tungsten oxide as efficient hole injection layer. <i>Organic Electronics</i> , 2012, 13, 796-806.	1.4	56
20	Solution-Processed Hydrogen Molybdenum Bronzes as Highly Conductive Anode Interlayers in Efficient Organic Photovoltaics. <i>Advanced Energy Materials</i> , 2014, 4, 1300896.	10.2	56
21	Polyhedral Oligomeric Silsesquioxane (POSS) Based Resists: Material Design Challenges and Lithographic Evaluation at 157 nm. <i>Chemistry of Materials</i> , 2004, 16, 2567-2577.	3.2	55
22	Vertical devices of self-assembled hybrid organic/inorganic monolayers based on tungsten polyoxometalates. <i>Microelectronic Engineering</i> , 2008, 85, 1399-1402.	1.1	54
23	Barrierless hole injection through sub-bandgap occupied states in organic light emitting diodes using substoichiometric MoOx anode interfacial layer. <i>Applied Physics Letters</i> , 2012, 100, .	1.5	54
24	Inorganic and Hybrid Interfacial Materials for Organic and Perovskite Solar Cells. <i>Advanced Energy Materials</i> , 2020, 10, 2000910.	10.2	54
25	Laser-Induced Cell Detachment and Patterning with Photodegradable Polymer Substrates. <i>Angewandte Chemie - International Edition</i> , 2011, 50, 4142-4145.	7.2	53
26	Biocompatible photolithographic process for the patterning of biomolecules. <i>Biosensors and Bioelectronics</i> , 2002, 17, 269-278.	5.3	52
27	Atomic Layer Deposited Aluminum and Zirconium Oxides for Surface Passivation of TiO ₂ in High-Efficiency Organic Photovoltaics. <i>Advanced Energy Materials</i> , 2014, 4, 1400214.	10.2	52
28	Lithium Doping of ZnO for High Efficiency and Stability Fullerene and Non-fullerene Organic Solar Cells. <i>ACS Applied Energy Materials</i> , 2019, 2, 1663-1675.	2.5	52
29	Multi-analyte capillary immunosensor for the determination of hormones in human serum samples. <i>Biosensors and Bioelectronics</i> , 2002, 17, 261-268.	5.3	50
30	Tuning the Emitting Color of Organic Light-Emitting Diodes Through Photochemically Induced Transformations: Towards Single-Layer, Patterned, Full-Color Displays and White-Lighting Applications. <i>Advanced Functional Materials</i> , 2007, 17, 3477-3485.	7.8	50
31	Reduced molybdenum oxide as an efficient electron injection layer in polymer light-emitting diodes. <i>Applied Physics Letters</i> , 2011, 98, 123301.	1.5	49
32	Tunneling transport in polyoxometalate based composite materials. <i>Applied Physics Letters</i> , 2003, 83, 488-490.	1.5	47
33	Large work function shift of organic semiconductors inducing enhanced interfacial electron transfer in organic optoelectronics enabled by porphyrin aggregated nanostructures. <i>Nano Research</i> , 2014, 7, 679-693.	5.8	46
34	A water soluble inorganic molecular oxide as a novel efficient electron injection layer for hybrid light-emitting diodes (HyLEDs). <i>Organic Electronics</i> , 2010, 11, 887-894.	1.4	45
35	Avoiding ambient air and light induced degradation in high-efficiency polymer solar cells by the use of hydrogen-doped zinc oxide as electron extraction material. <i>Nano Energy</i> , 2017, 34, 500-514.	8.2	45
36	Thin-Film Study on the Oxidation of Linseed Oil in the Presence of Selected Copper Pigments. <i>Chemistry of Materials</i> , 1999, 11, 2013-2022.	3.2	44

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37	Theoretical Investigation on the Effect of Protonation on the Absorption and Emission Spectra of Two Amine-Group-Bearing, Red "Push" Pull-Emitters, 4-Dimethylamino-4'-nitrostilbene and 4-(dicyanomethylene)-2-methyl-6-(dimethylamino) styryl-4H-pyran, by DFT and TDDFT Calculations. <i>Journal of Physical Chemistry A</i> , 2010, 114, 5580-5587.	1.1	42
38	Polyhedral oligomeric silsesquioxane (POSS) acrylate copolymers for microfabrication: properties and formulation of resist materials. <i>Microelectronic Engineering</i> , 2004, 73-74, 238-243.	1.1	38
39	Tungsten oxides as interfacial layers for improved performance in hybrid optoelectronic devices. <i>Thin Solid Films</i> , 2011, 519, 5748-5753.	0.8	38
40	Sol-gel synthesized, low-temperature processed, reduced molybdenum peroxides for organic optoelectronics applications. <i>Journal of Materials Chemistry C</i> , 2014, 2, 6290.	2.7	38
41	Porphyrin-Sensitized Evolution of Hydrogen using Dawson and Keplerate Polyoxometalate Photocatalysts. <i>ChemSusChem</i> , 2016, 9, 3213-3219.	3.6	37
42	Molecular Storage Elements for Proton Memory Devices. <i>Advanced Materials</i> , 2008, 20, 4568-4574.	11.1	36
43	Highly Efficient Bicolor (Green~Blue) Fluorescence Imaging in Polymeric Films. <i>Chemistry of Materials</i> , 2002, 14, 790-796.	3.2	35
44	Water-Soluble Lacunary Polyoxometalates with Excellent Electron Mobilities and Hole Blocking Capabilities for High Efficiency Fluorescent and Phosphorescent Organic Light Emitting Diodes. <i>Advanced Functional Materials</i> , 2016, 26, 2655-2665.	7.8	35
45	Surface Modification of ZnO Layers via Hydrogen Plasma Treatment for Efficient Inverted Polymer Solar Cells. <i>ACS Applied Materials & Interfaces</i> , 2016, 8, 1194-1205.	4.0	35
46	Absorbance and outgasing of photoresist polymeric materials for UV lithography below 193 nm including 157 nm lithography. <i>Microelectronic Engineering</i> , 2000, 53, 123-126.	1.1	34
47	UV exposure and temperature effects on curing mechanisms in thin linseed oil films: Spectroscopic and chromatographic studies. <i>Journal of Applied Polymer Science</i> , 2002, 84, 936-949.	1.3	30
48	Evaluation of poly(hydroxyethyl methacrylate) imaging chemistries for micropatterning applications. <i>Journal of Materials Chemistry</i> , 2004, 14, 3312.	6.7	29
49	Photocatalytic multielectron photoreduction of 18-tungstodiphosphate in the presence of organic compounds " production of hydrogen. <i>Journal of Photochemistry and Photobiology</i> , 1985, 30, 445-451.	0.6	28
50	Plasma oxidation of polyhedral oligomeric silsesquioxane polymers. <i>Journal of Vacuum Science & Technology B</i> , 2006, 24, 2678.	1.3	27
51	Enhanced Organic and Perovskite Solar Cell Performance through Modification of the Electron-Selective Contact with a Bodipy-Porphyrin Dyad. <i>ACS Applied Materials & Interfaces</i> , 2020, 12, 1120-1131.	4.0	27
52	Evaluation of siloxane and polyhedral silsesquioxane copolymers for 157 nm lithography. <i>Journal of Vacuum Science & Technology an Official Journal of the American Vacuum Society B, Microelectronics Processing and Phenomena</i> , 2002, 20, 2902.	1.6	26
53	Polymeric electrolytes for WO ₃ -based all solid-state electrochromic displays. <i>Microelectronic Engineering</i> , 2006, 83, 1414-1417.	1.1	26
54	Electrochemical biosensor microarray functionalized by means of biomolecule friendly photolithography. <i>Biosensors and Bioelectronics</i> , 2010, 25, 2115-2121.	5.3	26

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55	Vapor-deposited hydrogenated and oxygen-deficient molybdenum oxide thin films for application in organic optoelectronics. <i>Surface and Coatings Technology</i> , 2013, 230, 202-207.	2.2	26
56	Development mechanism study by dissolution monitoring of positive methacrylate photoresists. <i>Microelectronic Engineering</i> , 2000, 53, 489-492.	1.1	25
57	Photolithographic patterning of proteins with photoresists processable under biocompatible conditions. <i>Journal of Vacuum Science & Technology an Official Journal of the American Vacuum Society B, Microelectronics Processing and Phenomena</i> , 2001, 19, 2820.	1.6	25
58	Stochastic simulation studies of molecular resists. <i>Microelectronic Engineering</i> , 2007, 84, 1062-1065.	1.1	25
59	Fast Recovery of the High Work Function of Tungsten and Molybdenum Oxides via Microwave Exposure for Efficient Organic Photovoltaics. <i>Journal of Physical Chemistry Letters</i> , 2014, 5, 1871-1879.	2.1	25
60	A silanol-functionalized polyoxometalate with excellent electron transfer mediating behavior to ZnO and TiO ₂ cathode interlayers for highly efficient and extremely stable polymer solar cells. <i>Journal of Materials Chemistry C</i> , 2018, 6, 1459-1469.	2.7	25
61	Free-radical synthesis of narrow polydispersed 2-hydroxyethyl methacrylate-based tetrapolymers for dilute aqueous base developable negative photoresists. <i>Polymer</i> , 2002, 43, 1103-1113.	1.8	24
62	Hydrogen and nitrogen codoping of anatase TiO ₂ for efficiency enhancement in organic solar cells. <i>Scientific Reports</i> , 2017, 7, 17839.	1.6	24
63	The challenges of 157 nm nanolithography: surface morphology of silicon-based copolymers. <i>Materials Science and Engineering C</i> , 2003, 23, 995-999.	3.8	23
64	Partially Fluorinated, Polyhedral Oligomeric Silsesquioxane-Functionalized (Meth)Acrylate Resists for 193 nm Bilayer Lithography. <i>Chemistry of Materials</i> , 2006, 18, 4040-4048.	3.2	23
65	1-D polymeric photonic crystals as spectroscopic zero-power humidity sensors. <i>Microelectronic Engineering</i> , 2014, 115, 55-60.	1.1	23
66	Low Work Function Lacunary Polyoxometalates as Electron Transport Interlayers for Inverted Polymer Solar Cells of Improved Efficiency and Stability. <i>ACS Applied Materials & Interfaces</i> , 2017, 9, 22773-22787.	4.0	23
67	Mass spectroscopic and degassing characteristics of polymeric materials for 157 nm photolithography. <i>Applied Physics A: Materials Science and Processing</i> , 1999, 69, S929-S933.	1.1	22
68	Engineering of Porphyrin Molecules for Use as Effective Cathode Interfacial Modifiers in Organic Solar Cells of Enhanced Efficiency and Stability. <i>ACS Applied Materials & Interfaces</i> , 2018, 10, 20728-20739.	4.0	22
69	Laser plasma x-ray contact microscopy of living specimens using a chemically amplified epoxy resist. <i>Applied Physics Letters</i> , 1998, 72, 3258-3260.	1.5	21
70	Vanadium-sensitized photochemistry of heteropoly compounds. Mixed molybdo- and tungstovandates. <i>Inorganic Chemistry</i> , 1986, 25, 4386-4389.	1.9	20
71	157-nm Laser ablation of polymeric layers for fabrication of biomolecule microarrays. <i>Analytical and Bioanalytical Chemistry</i> , 2005, 381, 1027-1032.	1.9	20
72	Insights into the passivation effect of atomic layer deposited hafnium oxide for efficiency and stability enhancement in organic solar cells. <i>Journal of Materials Chemistry C</i> , 2018, 6, 8051-8059.	2.7	20

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73	Deep Ultraviolet Photoresist Based on Tungsten Polyoxometalates and Poly(Vinyl Alcohol) for Bilayer Photolithography. <i>Journal of the Electrochemical Society</i> , 1992, 139, 786-793.	1.3	18
74	Polymer self-assembled nano-structures and surface relief gratings induced with laser at 157nm. <i>Applied Surface Science</i> , 2007, 253, 7884-7889.	3.1	18
75	Optical Modeling of Hybrid Polymer Solar Cells Using a Transmission-Line Model and Comparison With Experimental Results. <i>IEEE Journal of Selected Topics in Quantum Electronics</i> , 2010, 16, 1784-1791.	1.9	18
76	Highly porous tungsten oxides for electrochromic applications. <i>Microelectronic Engineering</i> , 2013, 111, 149-153.	1.1	18
77	Organic solar cells of enhanced efficiency and stability using zinc oxide:zinc tungstate nanocomposite as electron extraction layer. <i>Organic Electronics</i> , 2019, 71, 227-237.	1.4	18
78	Determination of acid diffusion and energy deposition parameters by point e-beam exposure in chemically amplified resists. <i>Microelectronic Engineering</i> , 1996, 30, 295-299.	1.1	17
79	Dilute aqueous base developable resists for environmentally friendly and biocompatible processes. <i>Microelectronic Engineering</i> , 2002, 61-62, 819-827.	1.1	17
80	Molecular junctions made of tungsten-polyoxometalate self-assembled monolayers: Towards polyoxometalate-based molecular electronics devices. <i>Microelectronic Engineering</i> , 2011, 88, 2775-2777.	1.1	17
81	All-Organic Sulfonium Salts Acting as Efficient Solution Processed Electron Injection Layer for PLEDs. <i>ACS Applied Materials & Interfaces</i> , 2013, 5, 12346-12354.	4.0	17
82	Solution-processed nanostructured zinc oxide cathode interfacial layers for efficient inverted organic photovoltaics. <i>Microelectronic Engineering</i> , 2014, 119, 100-104.	1.1	17
83	Multi-electron reduction of Wells's Dawson polyoxometalate films onto metallic, semiconducting and dielectric substrates. <i>Physical Chemistry Chemical Physics</i> , 2019, 21, 427-437.	1.3	17
84	Application of a reaction-diffusion model for negative chemically amplified resists to determine electron-beam proximity correction parameters. <i>Journal of Vacuum Science & Technology an Official Journal of the American Vacuum Society B, Microelectronics Processing and Phenomena</i> , 1996, 14, 4252.	1.6	16
85	Electron beam lithography simulation for high resolution and high-density patterns. <i>Vacuum</i> , 2001, 62, 263-271.	1.6	16
86	Surface segregation of photoresist copolymers containing polyhedral oligomeric silsesquioxanes studied by x-ray photoelectron spectroscopy. <i>Journal of Vacuum Science & Technology an Official Journal of the American Vacuum Society B, Microelectronics Processing and Phenomena</i> , 2004, 22, 2526.	1.6	16
87	Characterization of various low-k dielectrics for possible use in applications at temperatures below 160 Å°C. <i>Journal of Physics: Conference Series</i> , 2005, 10, 218-221.	0.3	16
88	Energy transfer processes among emitters dispersed in a single polymer layer for colour tuning in OLEDs. <i>Physica Status Solidi (A) Applications and Materials Science</i> , 2008, 205, 2526-2531.	0.8	16
89	Incorporating triphenyl sulfonium salts in polyfluorene PLEDs: an all-organic approach to improved charge injection. <i>Journal of Materials Chemistry</i> , 2011, 21, 9296.	6.7	16
90	Photocatalytic processes by polyoxometalates. Splitting of water. The role of dioxygen. <i>Molecular Engineering</i> , 1993, 3, 231-239.	0.2	15

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91	Electrical characterization of molecular monolayers containing tungsten polyoxometalates. <i>Microelectronic Engineering</i> , 2006, 83, 1757-1760.	1.1	15
92	Layer-by-layer UV micromachining methodology of epoxy resist embedded microchannels. <i>Microelectronic Engineering</i> , 2006, 83, 1298-1301.	1.1	14
93	Atomic layer deposited zirconium oxide electron injection layer for efficient organic light emitting diodes. <i>Organic Electronics</i> , 2013, 14, 312-319.	1.4	14
94	Protein-Resistant Cross-Linked Poly(vinyl alcohol) Micropatterns via Photolithography Using Removable Polyoxometalate Photocatalyst. <i>ACS Applied Materials & Interfaces</i> , 2014, 6, 17463-17473.	4.0	14
95	Some photochemical aspects of polynuclear complexes of molybdenum and tungsten. <i>Journal of Photochemistry and Photobiology</i> , 1981, 17, 171-172.	0.6	13
96	A transmission line model for the optical simulation of multilayer structures and its application for oblique illumination of an organic solar cell with anisotropic extinction coefficient. <i>Journal of Applied Physics</i> , 2011, 110, 114506.	1.1	13
97	Tungsten polyoxometalate molecules as active nodes for dynamic carrier exchange in hybrid molecular/semiconductor capacitors. <i>Journal of Applied Physics</i> , 2014, 116, 143703.	1.1	13
98	Dehydration of molybdenum oxide hole extraction layers via microwave annealing for the improvement of efficiency and lifetime in organic solar cells. <i>Journal of Materials Chemistry C</i> , 2016, 4, 7683-7694.	2.7	13
99	Strippable aqueous base developable negative photoresist for high aspect ratio micromachining. <i>Microelectronic Engineering</i> , 2002, 61-62, 729-735.	1.1	12
100	Photoresist etch resistance enhancement using novel polycarbocyclic derivatives as additives. <i>Journal of Vacuum Science & Technology an Official Journal of the American Vacuum Society B, Microelectronics Processing and Phenomena</i> , 2003, 21, 141.	1.6	12
101	Self assembled structures on fluoro-polymers induced with laser light at 157nm. <i>Applied Surface Science</i> , 2005, 248, 248-253.	3.1	12
102	Highly transparent partially fluorinated methacrylate polymers for optical waveguides. <i>Microelectronic Engineering</i> , 2009, 86, 1142-1145.	1.1	12
103	Characterization of various insulators for possible use as low- k dielectrics deposited at temperatures below 200°C. <i>Microelectronics Reliability</i> , 2005, 45, 990-993.	0.9	11
104	Stochastic simulation studies of molecular resists for the 32nm technology node. <i>Microelectronic Engineering</i> , 2008, 85, 949-954.	1.1	11
105	Radiation Sensors Based on the Generation of Mobile Protons in Organic Dielectrics. <i>ACS Applied Materials & Interfaces</i> , 2013, 5, 5667-5674.	4.0	11
106	Theoretical study on the electronic structure of triphenyl sulfonium salts: Electronic excitation and electron transfer processes. <i>Chemical Physics Letters</i> , 2014, 601, 63-68.	1.2	11
107	Functionalized Zinc Porphyrins with Various Peripheral Groups for Interfacial Electron Injection Barrier Control in Organic Light Emitting Diodes. <i>ACS Omega</i> , 2018, 3, 10008-10018.	1.6	11
108	Guided cell adhesion, orientation, morphology and differentiation on silicon substrates photolithographically micropatterned with a cell-repellent cross-linked poly(vinyl alcohol) film. <i>Biomedical Materials (Bristol)</i> , 2019, 14, 014101.	1.7	11

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109	Micropatterned Films of Tungsten Nuclei for Subsequent Metallization Formed of a Phosphotungstic Acid-Based Negative Resist. <i>Journal of the Electrochemical Society</i> , 1992, 139, 2889-2894.	1.3	10
110	Photochemically-induced ligand exchange reactions of ethoxy-oxo-molybdenum(V) tetraphenylporphyrin in chlorinated solvents. <i>Polyhedron</i> , 2006, 25, 3427-3434.	1.0	10
111	Flexible organic light emitting diodes (OLEDs) based on a blue emitting polyfluorene. <i>Physica Status Solidi C: Current Topics in Solid State Physics</i> , 2008, 5, 3658-3662.	0.8	10
112	Aqueous base development and acid diffusion length optimization in negative epoxy resist for electron beam lithography. <i>Journal of Vacuum Science & Technology an Official Journal of the American Vacuum Society B, Microelectronics Processing and Phenomena</i> , 2000, 18, 3431.	1.6	9
113	Partially hydrogenated poly(vinyl phenol) based photoresist for near UV, high aspect ratio micromachining. <i>Journal of Vacuum Science & Technology an Official Journal of the American Vacuum Society B, Microelectronics Processing and Phenomena</i> , 2002, 20, 2968.	1.6	9
114	All-organic optocouplers based on polymer light-emitting diodes and photodetectors. <i>Physica Status Solidi (A) Applications and Materials Science</i> , 2008, 205, 2522-2525.	0.8	9
115	Surface modification of polyhedral oligomeric silsesquioxane block copolymer films by 157 nm laser light. <i>Journal of Applied Physics</i> , 2009, 105, .	1.1	9
116	Materials for lithography in the nanoscale. <i>International Journal of Nanotechnology</i> , 2009, 6, 71.	0.1	9
117	Thermally-Induced Acid Generation from 18-Molybdodiphosphate and 18-Tungstodiphosphate within Poly(2-Hydroxyethyl Methacrylate) Films. <i>Chemistry of Materials</i> , 2010, 22, 2730-2740.	3.2	9
118	Reduced transition metal oxides as electron injection layers in hybrid-PLEDs. <i>Microelectronic Engineering</i> , 2012, 90, 59-61.	1.1	9
119	Influence of the anion on the optoelectronic characteristics of triphenylsulfonium salts modified polymer light emitting devices. <i>Synthetic Metals</i> , 2013, 181, 37-44.	2.1	9
120	Transport properties of polyoxometalate containing polymeric materials. <i>Synthetic Metals</i> , 2003, 138, 267-269.	2.1	8
121	Hybrid organic-inorganic materials for molecular proton memory devices. <i>Organic Electronics</i> , 2009, 10, 711-718.	1.4	8
122	Effect of triphenylsulfonium triflate addition in wide band-gap polymer light-emitting diodes: improved charge injection, transport and electroplex-induced emission tuning. <i>RSC Advances</i> , 2012, 2, 11786.	1.7	8
123	Scalable fabrication of nanostructured p-Si/n-ZnO heterojunctions by femtosecond-laser processing. <i>Materials Research Express</i> , 2014, 1, 045902.	0.8	8
124	Organic photovoltaic performance improvement using atomic layer deposited ZnO electron-collecting layers. <i>Solid-State Electronics</i> , 2014, 101, 50-56.	0.8	8
125	Improved Stability of Polymer Solar Cells in Ambient Air via Atomic Layer Deposition of Ultrathin Dielectric Layers. <i>Advanced Materials Interfaces</i> , 2017, 4, 1700231.	1.9	8
126	A carbon-doped tantalum dioxide as a superior electron transport material for high performance organic optoelectronics. <i>Nano Energy</i> , 2020, 70, 104508.	8.2	8

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127	Silylation of epoxy functionalised photoresists for optical, e-beam lithography and micromachining applications. <i>Microelectronic Engineering</i> , 1998, 41-42, 335-338.	1.1	7
128	Silylation and Dry Development of Chemically Amplified Resists SAL601*, AZPN114*1, and Epoxidised Resist (EPR*1) for High Resolution Electron-Beam Lithography. <i>Japanese Journal of Applied Physics</i> , 1998, 37, 6873-6876.	0.8	7
129	Photoresist materials for 157-nm photolithography. <i>Materials Science and Engineering C</i> , 2001, 15, 159-161.	3.8	7
130	Negative (meth)acrylate resist materials based on novel crosslinking chemistry. <i>Microelectronic Engineering</i> , 2001, 57-58, 539-545.	1.1	7
131	Nano-scale spatial control over surface morphology of biocompatible fluoropolymers at 157Ånm. <i>Materials Science and Engineering C</i> , 2007, 27, 1191-1196.	3.8	7
132	Aqueous base developable: easy stripping, high aspect ratio negative photoresist for optical and proton beam lithography. <i>Microsystem Technologies</i> , 2008, 14, 1423-1428.	1.2	7
133	The role of metal/metal oxide/organic anode interfaces in efficiency and stability of bulk heterojunction organic photodetectors. <i>Microelectronic Engineering</i> , 2014, 117, 13-17.	1.1	7
134	Plasma induced degradation and surface electronic structure modification of Poly(3-hexylthiophene) films. <i>Polymer Degradation and Stability</i> , 2018, 149, 162-172.	2.7	7
135	Defect passivation in perovskite solar cells using an amino-functionalized BODIPY fluorophore. <i>Sustainable Energy and Fuels</i> , 2022, 6, 2570-2580.	2.5	7
136	Fabrication of Si nanodevices by optical lithography and anisotropic etching. <i>Microelectronic Engineering</i> , 1998, 41-42, 523-526.	1.1	6
137	Electron-beam lithography on multilayer substrates: experimental and theoretical study. , 1998, , .		6
138	Aqueous base developable epoxy resist for high sensitivity electron beam lithography. <i>Microelectronic Engineering</i> , 2000, 53, 453-456.	1.1	6
139	Resist process issues related to the glass transition changes in chemically amplified resist films. <i>Microelectronic Engineering</i> , 2003, 67-68, 283-291.	1.1	6
140	Exposure of molecular glass resist by e-beam and EUVIL. , 2007, , .		6
141	Optimized surface silylation of chemically amplified epoxidized photoresists for micromachining applications. <i>Journal of Applied Polymer Science</i> , 2010, 117, 2189-2195.	1.3	6
142	Photo-patternable fluorinated polyhedral oligomeric silsequioxane-functionalized (POSS-F) polymeric materials with ultra low dielectric constants. <i>Materials Chemistry and Physics</i> , 2012, 135, 880-883.	2.0	6
143	Solution processed multi-color organic light emitting diodes for application in telecommunications. <i>Microelectronic Engineering</i> , 2015, 145, 21-28.	1.1	6
144	Interfacial engineering for organic and perovskite solar cells using molecular materials. <i>Journal Physics D: Applied Physics</i> , 2020, 53, 263001.	1.3	6

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145	Gel formation theory approach for the modelling of negative chemically amplified e-beam resists. <i>Microelectronic Engineering</i> , 1997, 35, 157-160.	1.1	5
146	Calculation of energy deposition in thin resist films over multilayer substrates. <i>Microelectronic Engineering</i> , 1998, 41-42, 171-174.	1.1	5
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